PATENT ASSIGNMENT COVER SHEET

Electronic Version v1.1 Stylesheet Version v1.2

NEW ASSIGNMENT

EPAS ID: PAT3540541

SUBMISSION TYPE:	NEW ASSIGNMENT
NATURE OF CONVEYANCE:	ASSIGNMENT

CONVEYING PARTY DATA

Name	Execution Date
DIGVIJAY SINGH CHAUHAN	09/16/2015
AMIT KUMAR	09/21/2015
THOMAS S LACKI	09/23/2015

RECEIVING PARTY DATA

Name:	UNIFRAX I LLC	
Street Address:	600 RIVERWALK PARKWAY	
Internal Address:	SUITE 120	
City:	TONAWANDA	
State/Country:	NEW YORK	
Postal Code:	14150	

PROPERTY NUMBERS Total: 1

Property Type	Number
Application Number:	14845984

CORRESPONDENCE DATA

Fax Number: (440)808-0657

Correspondence will be sent to the e-mail address first; if that is unsuccessful, it will be sent using a fax number, if provided; if that is unsuccessful, it will be sent via US Mail.

Phone: 440-808-0011

Email:docket@patentandtm.comCorrespondent Name:CURATOLO SIDOTI CO., LPAAddress Line 1:24500 CENTER RIDGE RD.

Address Line 2: SUITE 280

Address Line 4: CLEVELAND, OHIO 44145

ATTORNEY DOCKET NUMBER:	UNF.P9771
NAME OF SUBMITTER:	VINCENT A. CORTESE
SIGNATURE:	/Vincent A. Cortese/
DATE SIGNED:	09/24/2015

Total Attachments: 2

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PATENT 503493916 REEL: 036646 FRAME: 0100

ASSIGNMENT

We, Digvijay Singh CHAUHAN, residing at 304 Darwin Drive, Buffalo, New York, 14260; Amit KUMAR, residing at 20 Huntwood Court, Getzville, New York, 14068; and Thomas S. LACKI, residing at 12327 South Blossom Lea, Alden, New York, 14004, have invented certain new and useful improvements in High Temperature Resistant Insulation Mat and Unifrax I LLC, a limited liability company organized and doing business under the laws of the State of Delaware, having a place of business at 600 Riverwalk Parkway, Suite 120, Tonawanda, New York, 14150, desires to acquire the rights to this invention.

In consideration of one dollar (\$1.00), receipt and sufficiency of which is hereby acknowledged, and other good and valuable considerations, We, Digvijay Singh CHAUHAN, Amit KUMAR, and Thomas S. LACKI, hereby sell, assign, and transfer to Unifrax I LLC, its successors and assigns, the entire right, title, and interest in and to this invention relating to High Temperature Resistant Insulation Mat and any improvements thereon; the so-entitled United States Non-Provisional Application for Patent which was filed on September 4, 2015, and which bears United States Application For Patent Serial No. 14/845,984; and Attorney Docket No. UNF.P9771; any and all continuations, continuations-in-part, divisions and renewals thereon; all reissues or extensions thereof; all reexamination certificates; all United States Letters Patent granted thereon; and any and all Letters Patents on said invention, and applications therefor, including all rights to claim priority, in any and all countries foreign to the United States of America.

We hereby authorize and request the Director of the United States Patent and Trademark Office to issue all United States Letters Patent on said invention and application, or applications resulting therefrom, to Unifrax I LLC, as assignee of the entire right, title, and interest.

We further agree that during and subsequent to our employment with Unifrax I LLC, on request and without further consideration, but at the sole expense of Unifrax I LLC, we will with

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PATENT REEL: 036646 FRAME: 0101 respect to this invention and this application or any subsequent application on this invention communicate to counsel for Unifrax I LLC, its successors and assigns all facts known to us; testify in all legal proceedings; sign all lawful papers; execute all applications; make all rightful oaths; generally do everything possible to aid Unifrax I LLC, it successors and assigns to obtain and enforce lawful patent protection for said invention in the United States and countries foreign thereto; and vest the entire right, title and interest in and to said invention and any and all applications for letters patent therefor and letters patent thereon in Unifrax LLC, its successors and assigns.